[DESCRIPTION OF A MARK]

- 101 A substrate
- 102a, 102b and 102c First wiring lines
- 103 A first insulating layer
- 104 and 105 Active layers
- 106 A second insulating layer
- 107a, 107b, 107c and 107d Second wiring lines
- (107al, 107bl, 107cl and 107dl First conductive layers
- 107a2, 107b2, 107c2 and 107d2 Second conductive layers
- 107d3 A third conductive layer)
- 108 A first interlayer insulating layer
- 109~111 Third wiring lines
- (109, 110 Source wiring lines
- 111 A drain wiring line)
- 201 A substrate
- 202a, 202b and 202c First wiring lines
- 203 A first insulating layer
- 204 An active layer
- 205 A second insulating layer
- 206a, 206b and 206c Second wiring lines
- (206al, 206bl and 206cl First conductive layers
- 206a2, 206b2 and 206c2 Second conductive layers
- 206a3 A second conductive layer)
- 207 A capacitor wiring line
- (207a A first conductive layer
- 207b A second conductive layer)
- 208 A first interlayer insulating layer
- 209 A source wiring line
- 210 A drain wiring line
- 211 A second interlayer insulating layer
- 212 Black masks
- 213 A third interlayer insulating layer
- 214 A pixel electrode
- 215 and 216 Channel formation regions

- A substrate with an insulating surface
- 602 A pixel matrix circuit
- 603 A source driver circuit
- 604 A gate driver circuit
- 605 A signal processing circuit
- 606 An FPC
- 1007 An opposite substrate
- 701 A pixel matrix circuit
- 702a and 703a Shift register circuits
- 702b and 703b Level shifter circuits
- 702c and 703c Buffer circuits
- 703d A sampling circuit
- 704 A precharge circuit
- 2001 A main body
- 2002 An audio output unit
- 2003 An audio input unit
- 2004 A display device
- 2005 Operation switches
- 2006 An antenna
- 2101 A main body
- 2102 A display device
- 2103 An audio input unit
- 2104 Operation switches
- 2105 A battery
- 2106 An image receiving unit
- 2201 A main body
- 2202 A camera unit
- 2203 An image receiving unit
- 2204 Operation switches
- 2205 A display device
- 2301 A main body

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2302 Display devices
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2303 Arm units

2401 A main body

2402 A light source

2403 A display device

2404 A polarization beam splitter

2405 Reflector

2406 Reflector

2407 A screen

2501 A main body

2502 A light source

2503 A display device

2504 An optical system

2505 A screen

[BRIEF DESCRIPTION OF THE FIGURES]

- [Fig. 2](A) 画素TFT部 --- A pixel TFT portion 保持容量部 --- A storage capacitor portion
 - (B) 保持容量部 --- A storage capacitor portion
- [Fig. 3](A) リンの添加工程 --- A phosphorus doping step
 - (B) ボロンの添加工程 --- A boron doping step
 - (C) 裏面露光工程、リンの添加工程 --- Aback side exposure step, A phosphorus doping step
- [Fig. 9](A) 画素TFT部 --- A pixel TFT portion 保持容量部 --- A storage capacitor portion
 - (B) 画素TFT部 --- A pixel TFT portion

 保持容量部 --- A storage capacitor portion
- [Fig. 10](B) 画素TFT部 --- A pixel TFT portion 保持容量部 --- A storage capacitor portion
- [Fig. 11](B) 画素TFT部 --- A pixel TFT portion

保持容量部 --- A storage capacitor portion

- [Fig. 12](A) リンによるゲッタリング工程 --- A gettering step by phosphorus
 - (C) ボロンの添加工程 --- A boron doping step
 - (D) 裏面露光工程、リンの添加工程 --- A back side exposure step, A phosphorus doping step